

Terahertz Light Emission and Lasing in Current-Driven Graphene-based 2D Nano- and Plasmonic-Structures

Taiichi Otsuji

Tohoku University, Japan

Abstract

Graphene has attracted considerable attention due to its massless and gapless energy spectrum of Dirac Fermions as well as strong light-matter interactions via plasmon-polaritons. This paper highlights recent advances in terahertz (THz) light emission and lasing in current-driven graphene-based 2D nano-structures. The dual-gate graphene channel transistor (DG-GFET) structure promotes carrier population inversion in the lateral p-i-n junctions under complementary dual-gate biased and forward drain biased conditions, promoting spontaneous incoherent THz light emission. A laser cavity structure implemented in the active gain area can transcend the incoherent light emission to the single-mode lasing. We designed and fabricated the distributed feedback (DFB) DG-GFET. The GFET channel consists of a double layer (non-Bernal) epitaxial graphene, providing an intrinsic field-effect mobility exceeding $100,000 \text{ cm}^2/\text{Vs}$. The teeth-brush-shaped DG forms the DFB cavity having the fundamental mode at 4.96 THz. THz emission from the sample was measured using a Fourier-transform spectrometer with a 4.2K-cooled Si bolometer. Broadband rather intense ($\sim 10 \text{ }\mu\text{W}$) amplified spontaneous emission from 1 to 7.6 THz and weak ($\sim 0.1 \text{ }\mu\text{W}$) single-mode lasing at 5.2 THz were observed at 100K in different samples. Present structure offers a weak gain overlapping due to poor THz photon-field confinement, resulting in a wide variation from single-mode lasing to broadband incoherent emission depending on graphene quality (carrier momentum relaxation time). Further improvements are now under way.

Conclusion & Significance: Carrier-injection pumping of graphene can enable negative-dynamic conductivity in the THz range, which may lead to a new type of THz lasers. Current-driven plasmon instabilities in dual-grating-gate GFET structures as well as plasmon-assisted resonant tunneling in gated double-graphene-layered nano-capasitor structures can promote the generation and amplification of THz waves, leading to intense, room-temperature THz lasing.

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Biography:

Taiichi Otsuji is a professor at the Research Institute of Electrical Communication (RIEC), Tohoku University, Sendai, Japan. He received the Ph.D degree in electronic engineering from Tokyo Institute of Technology, Tokyo, Japan in 1994. From 1984 to 1999 he worked for NTT Laboratories, Kanagawa, Japan. In 1999 he joined Kyushu Institute of Technology. He joined RIEC, Tohoku University, in 2005. His current research interests include terahertz electronic, photonic and plasmonic materials/devices and their applications. He has authored and co-authored 250 peer-reviewed journal papers and more than 150 invited presentations in academic international conferences. He was awarded the Outstanding Paper Award of the 1997 IEEE GaAs IC Symposium, and has served as an IEEE Electron Device Society Distinguished Lecturer since 2013. He is a Fellow of the IEEE, OSA and JSAP, and a member of the MRS, SPIE, and IEICE



Speaker Publications:

1.Yadav D, Tamamushi G, Watanabe T, Mitsushio J, Tobah Y, Sugawara K, Dubinov AA, Satou A, Ryzhii M, Ryzhii V and Otsuji T. Terahertz light-emitting graphene-channel transistor toward single-mode lasing. *Nanophoton.* **7** 741-752 (2018).

2.Polischuk OV, Fateev D, Otsuji T and Popov VV. Plasmonic amplification of terahertz radiation in a periodic graphene structure with the carrier injection. *Appl. Phys. Lett.* **111** 081110 (2017).

3.Yadav D, Boubanga-Tombet S, Watanabe T, Arnold S, Ryzhii V and Otsuji T. Terahertz wave generation and

detection in double-graphene layered van der Waals heterostructures. *2D Mater.* **3** 045009 (2016).

4. Koseki Y, Otsuji T, Popov VV and Satou A. Giant plasmon instability in a dual-grating-gate graphene field-effect transistor. *Phys. Rev. B* **93** 245408 (2016).

5. Watanabe T, Fukusima T, Yabe Y, Boubanga-Tombet SA, Satou A, Dubinov AA, Ya Aleshkin V, Mitin V, Ryzhii V and Otsuji T. The gain enhancement effect of surface plasmon polaritons on terahertz stimulated emission in optically pumped monolayer graphene. *New J. Phys.* **15** 075003 (2013).

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